

NOV 19 2004

Attorney Docket No.: 99CON114P

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re Application of: Llu, et al.

Serial No.: 09/575,055

Filed: May 19, 2000

For: **Method for Selective Fabrication of  
High Capacitance Density Areas in a  
Low Dielectric Constant Material**

Art Unit: 2825

Examiner: Luu, Chuong A.

**AMENDMENT AND RESPONSE TO NON-FINAL OFFICE ACTION**

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Dear Sir/Madam:

This is in response to the Non-Final Office Action dated July 27, 2004 in the above-referenced patent application. Please enter and consider the following amendments and remarks.